

HOMEWORK 1.

Due: Wednesday, February 15, 2018.

This is an individual assignment!**The goal of this assignment is to get familiar with the class technology. It could be fairly long – knowledge of some scripting language (like Python) could be useful.****1. Models**

Use the SPICE model to characterize the class 32nm LP CMOS process; parameter files correspond to devices n105 and p105 in the process directory (~ee241/synopsys-32nm/hspice/saed32nm.lib). The nominal supply voltage for this process is 1.05V. Note that the devices need to be instantiated as subcircuits in SPICE (Use an X prefix, not M).

- a) Determine the threshold voltage V_{Th} , for the NMOS and PMOS devices (for $V_{BS} = 0$, $L = 32\text{nm}$ and $W = 1\mu\text{m}$), by extrapolating from the I_D - V_{GS} curve at low V_{DS} . Explain your circuit setup. How does this result compare to values reported in the model file and the DC OP analysis?
- b) For the model used in class
$$I_{DSat} = \frac{W}{L} \frac{\mu_{eff} C_{ox} E_C L}{2} \frac{(V_{GS} - V_{Th})^2}{(V_{GS} - V_{Th}) + E_C L},$$
 find the values of $E_C L$ that best fit the NMOS and PMOS characteristics. Use the V_{Th} value from part a). Note that you may want to modify the I_{DSat} equation to account for finite output resistance.
- c) We will try to extract the parameters V_{Th} and α for the alpha-power-law model
$$I_D = K(V_{GS} - V_{Th})^\alpha$$
 from SPICE simulations. Use Matlab to determine K , V_{Th} and α (hint: use the `lsqcurvefit` function). Determine the parameters for both NMOS and PMOS transistors.
- d) By setting $\alpha = 1$, find the best V_{Th} 's that correspond to linear dependence of current on V_{GS} .
- e) Find the subthreshold slope for both NMOS and PMOS devices.

2. Transistor sizing

In this problem, we will explore optimal transistor sizing.

- a) Using SPICE and 32nm LP model with 1.05V supply, find the required width of the PMOS transistor that minimizes the propagation delay $(t_{pHL} + t_{pLH})/2$ for the CMOS inverter. NMOS transistor width is fixed at 100nm. We will call this an optimally or symmetrically sized inverter.
- b) Find the intrinsic delay of this inverter, p . It is set by the ratio of diffusion to gate capacitances, but it is better to find it from the delay measurements.
- c) Optimally size the CMOS NAND2 gate. Find the required width (W) for the NMOS transistors in the pull-down such that the equivalent resistance of the pull-down network is the same as the equivalent resistance of the pull down transistor in an inverter from part a). Use hand analysis with parameters from Problem 1. (In case you haven't been able to solve Problem 1, you can use $E_{cL} = 0.8V$, $V_{DD} = 1V$, and $V_{Th} = 0.5V$). Compare with SPICE and discuss any discrepancies.
- d) Find the logical effort and the intrinsic delay of the NAND2 gate from part c).
- e) Now find a library cell for the NAND2 gate in the class standard cell library. Find the logical effort and the intrinsic delay from the datasheet or the .lib file.
- f) Repeat part c) for a NAND3 gate. Compare with SPICE and discuss any discrepancies. Find the logical effort of this gate.
- g) Optimally size NOR2 gate by using SPICE to match the inverter from part a). Find the logical effort.

3. Transistor sizing

Optimally size a transmission gate in 32nm LP model with 1.05V supply. To do that correctly, a symmetrically-sized inverter should drive pass-transistor inputs of the transmission gate.

- a) Calculate logical effort of the optimally-sized transmission gate.
- b) Set the NMOS size to be equal to the PMOS size, and calculate again the logical effort. Compare it to part a)

4. Design a one-hot 5-32 decoder using a typical VLSI flow

- a) Work through GCD: VLSI's Hello World (on the course website/Github), a brief tutorial that will describe how industry tools translate RTL code to final layout. Try to understand the high-level concepts of what is happening and don't worry too much about the details for now. Turn in:

-The first 45 lines of the post-place-and-route Verilog netlist

-Answer the following questions: Why are you generally not worried when you have hold time violations after synthesis? Why does the tutorial example (page 9 of the PDF) fail timing even though the delay is less than the clock period (0.5)? Why might you want to set a conservative clock_uncertainty?

b) In your /scratch/username directory on hpse-(9-15).eecs.berkeley.edu, type:

b) source ~ee241/tutorials/ee241.bashrc

git clone ~ee241/tutorials/decoder

Edit src/decoder.v, and write a verilog description of a 5 to 32 decoder. Open src/decoder_tb.v (a test bench we wrote for you) and try to understand the file. Next, edit build-rvt/constraints.tcl and build-rvt/Makefrag and describe the following constraints: 30fF load capacitance on each output pin, inputs driven by a minimum sized inverter (Hint: it's not what's default! Take a look at the directory ~ee241/synopsys-32nm/saed32nm_rvt/), and target maximum frequency (anything that will make you meet timing post P&R). Then synthesize, place-and-route, and test the design (dc-syn/, icc-par/, vcs-sim-gl-par/), and turn in:

-A screenshot of the layout

-The critical path in ns

-A post P&R DVE simulation waveform showing correct functionality and the critical path